

B-STAGEABLE UNDERFILL ENCAPSULANT AND METHOD FOR ITS APPLICATION

FIELD OF THE INVENTION

The present invention is related to an underfill encapsulant and a method for its application to semiconductor wafers.

BACKGROUND OF THE INVENTION

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This invention relates to underfill encapsulant compounds prepared from epoxies and phenolic resins to protect and reinforce the interconnections between an electronic component and a substrate in a microelectronic device. Microelectronic devices contain multiple types of electrical circuit components, mainly transistors assembled together in integrated circuit (IC) chips, but also resistors, capacitors, and other components. These electronic components are interconnected to form the circuits, and eventually are connected to and supported on a carrier or a substrate, such as a printed wire board. The integrated circuit component may comprise a single bare chip, a single encapsulated chip, or an

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2025 RELEASE UNDER E.O. 14176

encapsulated package of multiple chips. The single bare chip can be attached to a lead frame, which in turn is encapsulated and attached to the printed wire board, or it can be directly attached to the printed wire board. These chips are originally formed as a semiconductor wafer containing multiple chips. The semiconductor wafer is diced as desired into individual chips or chip packages.

Whether the component is a bare chip connected to a lead frame, or a package connected to a printed wire board or other substrate, the connections are made between electrical terminations on the electronic component and corresponding electrical terminations on the substrate. One method for making these connections uses polymeric or metallic material that is applied in bumps to the component or substrate terminals. The terminals are aligned and contacted together and the resulting assembly is heated to reflow the metallic or polymeric material and solidify the connection.

During its normal service life, the electronic assembly is subjected to cycles of elevated and lowered temperatures. Due to the differences in the coefficient of thermal expansion for the electronic component, the interconnect material, and the substrate, this thermal cycling can stress the components of the assembly and cause it to fail. To prevent the failure, the gap between the component and the substrate is filled with a polymeric encapsulant, hereinafter called underfill or underfill encapsulant, to reinforce the interconnect material and to absorb some of the stress of the thermal cycling.

Two prominent uses for underfill technology are for reinforcing packages known in the industry as chip scale packages (CSP), in which a chip package is attached to a substrate, and flip-chip packages in which a chip is attached by an array of interconnections to a substrate.

In conventional capillary flow underfill applications, the underfill dispensing and curing takes place after the reflow of the metallic or polymeric interconnect. In this procedure, flux is initially applied on the metal pads on the substrate. Next, the chip is placed on the fluxed area of the substrate, on top of the soldering site. The assembly is then heated to allow for reflow of the solder joint. At this point, a measured amount of underfill encapsulant material is dispensed along one or more peripheral sides of the electronic assembly and capillary action within the component-to-substrate gap draws the material inward. After the gap is filled, additional underfill encapsulant may be dispensed along the complete assembly periphery to help reduce stress concentrations and prolong the fatigue life of the assembled structure. The underfill encapsulant is subsequently cured to reach its optimized final properties.

Recently, attempts have been made to streamline the process and increase efficiency by coating the underfill encapsulant directly on the semiconductor wafer before the wafer is diced into individual chips. The coating procedure, which can be performed via various methods, including screen printing, stencil printing and spin coating, allows for a single application of underfill to a single semiconductor wafer that is later diced into a large number of individual chips.

In order to be useful as a wafer level underfill encapsulant, the underfill must have several important properties. First, the material must be easy to apply uniformly on the wafer so that the entire wafer has a consistent coating. The underfill encapsulant that is applied to the wafer must not interfere with the clean dicing of the wafer into individual chips. The underfill encapsulant must be B-stageable, which means that the underfill must be

solidified after its placement on a wafer to provide a smooth, non-tacky coating with minimal residual solvent.

If the starting underfill material is a solid, the solid is dispersed or dissolved in a solvent to form a paste and the paste applied to the wafer.

- 5 The underfill is then heated to evaporate the solvent, leaving a solid, but uncured, underfill on the wafer. If the starting underfill material is a liquid or paste, the underfill is dispensed onto the wafer and heated to partially cure it to a solid state.

- The B-stage process usually occurs at a temperature lower than
10 about 150 °C without prematurely curing the underfill encapsulant. The final curing of the underfill encapsulant must be delayed until after the solder fluxing (in the situation that solder is the interconnect material) and interconnection, which occurs at a temperature of 183 °C in the case of tin/lead eutectic solder. The final curing of the underfill should occur rapidly
15 after the solder bump flow and interconnection. During this final attachment of the individual chips to a substrate, the underfill encapsulant must flow in order to enable fillet formation, flux the solder bumps, and provide good adhesion between the chip, or chip passivation layer, the substrate, or the solder mask, and the solder joints. In particular instances, it can be useful to
20 provide an unfilled liquid curable fluxing material directly on the substrate to facilitate interconnection.

SUMMARY OF THE INVENTION

- 25 The invention relates to a curable B-stageable underfill encapsulant composition that is applied directly onto semiconductor wafers before the wafers are diced into individual chips. The composition comprises a

thermally curable resin system comprising an epoxy resin, a phenol-containing compound, such as phenol or phenolic resin, a solvent, an imidazole-anhydride catalyst, inorganic fillers, and optionally, fluxing agents and/or wetting agents. Various other additives, such as defoaming agents, 5 adhesion promoters, flow additives and rheology modifiers may also be added as desired. The underfill encapsulant is B-stageable to provide a coating on the wafer that is smooth, non-tacky and will allow the wafer to be cleanly diced into individual chips. The individual chips are then attached directly to a substrate. In an alternative embodiment, an unfilled liquid 10 curable fluxing material is applied directly to the substrate to promote interconnection with the chip.

DETAILED DESCRIPTION OF THE INVENTION

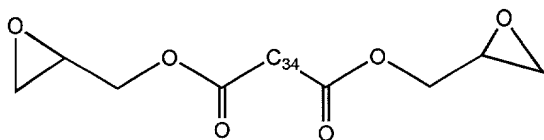
15 The resins used in the underfill encapsulant composition of the present invention are curable compounds, which means that they are capable of polymerization. As used in this specification, to cure will mean to polymerize, with cross-linking. Cross-linking, as understood in the art, is the 20 attachment of two-polymer chains by bridges of an element, a molecular group, or a compound, and in general takes place upon heating.

Ingredients of the B-stageable underfill encapsulant composition of the present invention include a blend of one or more epoxy resins and a phenolic-containing compound, an imidazole-anhydride adduct which acts as 25 a catalyst, one or more solvents, and an inorganic filler. Optionally, fluxing agents, air release agents, flow additives, adhesion promoters, rheology modifiers, surfactants and other ingredients may be included. The

combination thereof. Examples of aliphatic epoxy include Flex Epoxy 1.

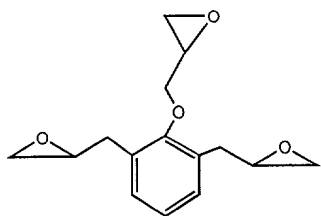
Example of aromatic epoxies include RAS-1, RAS-5, and Flex Epoxy-3

Flex Epoxy 1

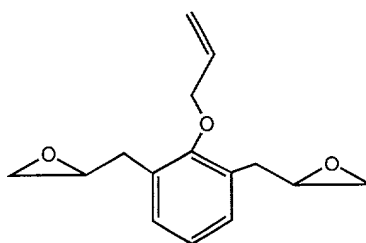


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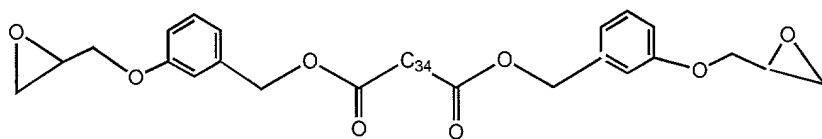
RAS-1



RAS-5

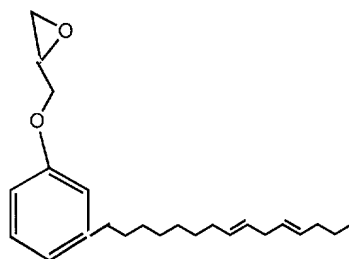


Flex Epoxy-3



Example of unsaturated epoxy includes Cardolite NC513.

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Cardolite NC513

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designated ZX-1059. The resin commercially available from Vantico as XP71756.00 may also be utilized.

The desired phenol-containing compound is combined with the non-phenolic resin to produce the admixture. The phenol-containing compound is preferably phenol or phenolic resin and is chosen to provide a high glass transition temperature to the final composition. Especially preferred phenolic resins are phenolic novolac resins. Especially preferred phenol are bisphenol-A and dially bisphenoly A phenolic resins. Commercially available examples of phenolic novolac resins are Durez 12686 (Oxychem), HRJ – 2190 (Schenectady), SP-560 (Schenectady), HRJ-2606 (Schenectady), HRJ-1166 (Schenectady), HRJ-11040 (Schenectady), HRJ-2210 (Schenectady), CRJ-406 (Schenectady), HRJ-2163 (Schenectady), HRJ-10739 (Schenectady), HRJ-13172 (Schenectady), HRJ-11937 (Schenectady), HRJ-2355 (Schenectady), SP-25 (Schenectady), SP-1068 (Schenectady), CRJ-418 (Schenectady), SP-1090 (Schenectady), SP-1077 (Schenectady), SP-6701 (Schenectady), HRJ-11945 (Schenectady), SP-6700 (Schenectady), HRJ-11995 (Schenectady), SP-553 (Schenectady), HRJ-2053 (Schenectady), SP-560 (Schenectady), BRWE5300 (Georgia-Pacific Resins), BRWE5555 (Georgia-Pacific Resins), and GP2074 (Georgia-Pacific Resins).

In addition to the resins, an imidazole-anhydride adduct is included in the underfill composition as a catalyst. The adduct provides different properties to the underfill than the properties provided by the inclusion of imidazole and anhydride as separate components. Preferred imidazoles that may be included in the adduct include non-N-substituted imidazoles such as 2-phenyl-4-methyl imidazole, 2-ethyl-4-methyl-imidazole, 2-phenyl imidazole and imidazole. Other useful imidazole components include alkyl-substituted imidazole, N-substituted imidazole and mixtures thereof. The adduct also

comprises an anhydride component. The preferred anhydride is preferably a cycloaliphatic anhydride and most preferably pyromellitic dianhydride, commercially available as PMDA from Aldrich. Additional preferred anhydrides include methylhexa-hydro phthalic anhydride, commercially available as MHPA from Lonza Inc. Intermediates and Actives. Other anhydrides that may be utilized include methyltetra-hydrophthalic anhydride, nadic methyl anhydride, hexa-hydro phthalic anhydride, tetra-hydro phthalic anhydride, phthalic anhydride, dodecyl succinic anhydride, bisphenyl dianhydride, benzophenone tetracarboxylic dianhydride, and mixtures thereof. A preferred catalyst is synthesized by combining 1 mole part 1,2,4,5-benzenetetracarboxylic dianhydride and 2 mole part 2-phenyl-4-methylimidazole. Both components are first dissolved in acetone under heat and when both are combined the imidazole-dianhydride salt forms as a precipitate. This preferred catalyst, in combination with an epoxy and solvent, produces an underfill having an onset curing temperature well above 150 °C and a cure peak temperature above 183 °C. Further, the preferred catalyst provides improved latency as opposed to the use of just an imidazole

A fluxing agent may also be incorporated into the underfill composition. The fluxing agent primarily removes metal oxides and prevents reoxidation. While many different fluxing materials may be employed, the fluxing agent is preferably chosen from the group carboxylic acids. These carboxylic acids include rosin gum, dodecanedioic acid (commercially available as Corfree M2 from Aldrich), adipic acid, sebacic acid, polysebacic polynhydride, maleic acid, tartaric acid, and citric acid. The flux agent may also be chosen from the group that includes alcohols, hydroxyl acid and hydroxyl base. Preferable fluxing materials include polyols such as ethylene glycol, glycerol, 3-[bis(glycidyl oxy methyl) methoxy]-1,2-propane diol, D-

vinylidene chloride, and vinyl chloride. A preferred inorganic filler is silica, commercially available under the trade name FUSOFE® from Admatechs.

Additional ingredients may be added to the underfill encapsulant to produce a composition with the desired properties. For example,

- 5 monofunctional reactive diluents can incrementally delay the increase in viscosity without adversely affecting the physical properties of the cured underfill. Preferred diluents include p-tert-butyl-phenyl glycidyl ether, allyl glycidyl ether, glycerol dibglycidyl ether, glycidyl ether of alkyl phenol (commercially available from Cardolite Corporation as Cardolite NC513), and
- 10 Butanedioldiglycidylether (commercially available as BDGE from Aldrich), although other diluents may be utilized. Surfactants may be utilized to aid in the prevention of process voiding during the flip-chip bonding process and subsequent solder joint reflow and material curing. Various surfactants which may be utilized include organic acrylic polymers, silicones,
- 15 polyoxyethylene/polyoxypropylene block copolymers, ethylene diamine based polyoxyethylene/polyoxypropylene block copolymers, polyol-based polyoxyalkylenes, fatty alcohol-based polyoxyalkylenes, fatty alcohol polyoxyalkylene alkyl ethers and mixtures thereof. In addition, coupling agents, air release agents, flow additives, adhesion promoters and other
- 20 ingredients may also be added as desired.

A preferred embodiment of the underfill encapsulant of the present invention comprises an admixture of at least one epoxy resin and at least one phenol/phenolic resin, an imidazole-anhydride adduct as a catalyst, a fluxing agent, solvent, inorganic filler and other ingredients as desired. The resin

25 admixture will comprise in the range of about 0.1 wt % to about 99.9 wt % of the epoxy resin and about 0.1 to about 99.9 wt % of the phenolic resin. Preferably, the admixture will be comprised of in the range of about 40 wt %

to the substrate prior to placement of the chip. After the underfill is B-stage solidified on the wafer and the wafer is diced into individual chips, the chip is placed on the substrate with the B-staged material adjacent to and in contact with the unfilled liquid curable material. The unfilled liquid curable material facilitates improved solder fluxing and interconnections between the substrate and the individual chips. As shown in Examples 7 - 9, when the composition of the alternative embodiment is placed on a substrate and a chip having the B-stageable composition is placed onto the substrate, a superior interconnect is formed after the completion of the reflow process.

10 The invention may be better understood by reference to the following examples:

EXAMPLE 1: An underfill encapsulant composition was manufactured comprising 50 parts each of EPON 826 (Shell Epoxy Resins) and HRJ2190 (Schenectady International) which were blended together with 53 parts of propylene glycol ethyl methyl acetate (PGMEA – Aldrich Chemical). The mixture was heated to 143 °C for 5 hours and 30 minutes. The resulting homogeneous blend was cooled to 25 °C. After cooling, 108 parts of FUSOFE (Admatechs), 0.5 parts of BYK-W 9010 (BYK-Chemie), 0.5 parts of A-187 (Silquest), 1.8 parts of vinylmethyl siloxane-dimethylsiloxane copolymer (VDT-131 from Gelest, Inc.), and 0.4 parts of 2-phenyl-4-methyl imidazole (2P4MZ)/pyromellitic dianhydride (PMDA) adduct were added. The formulation was then dispersed in a Double Planetary Ross mixer for six hours. The mixed underfill material was bubble free, did not trap air on slow shearing, and had a viscosity of 30,000 cP (30 Pa's) at a shear rate of 1s⁻¹. The underfill material was then dispensed on glass cover slips (25 mm x 25 mm) by a stenciling process, to produce a 110 micron thick coating. The

coated slips were then placed on a hot plate that was preheated to 135 °C and B-staged for 15 minutes. After the B-stage process, the coatings were found to be smooth, non-tacky and void free. The glass transition temperature of the coating was found to be around 46 °C by DSC. The glass transition temperature was within the desired range for providing clean dicing of an wafer that is coated with a B-staged underfill composition.

EXAMPLE 2: Underfill compositions were formulated according to the method set out in Example 1. The material was dispensed on a piece of OSP Cu finished FR4 board. Eutectic solder balls of 20 mil diameter were placed in the material. Excess material was sheared off by placing a 25mm x 25 mm glass cover slip on top of the material and pushing the glass slip into contact with the solder balls. In this way, the thickness of the material was controlled to within 20 mil. After removing the slip, the assembly was placed on a vacuum oven at 120 °C and B-staged for 30 minutes. After the B-stage process, a smooth, void-free, and non-tacky coating was obtained. Since solvent was evaporated during the B-staging and the coating was about 20% thinner, the solder balls in the coating were protruding from the coating. After this specimen was placed face down on a 1' x 3' glass slide, the entire assembly was placed on a hot plate that was preheated to 160 °C. After two minutes, this assembly was transferred to another hot plate that was preheated to 240 °C for one more minute. Checking from the glass slide, it was observed that the solder balls wetted the glass slide and enlarged in area. This solder ball enlargement suggested the encapsulant material was not prematurely cured and did not interfere with solder spreading and interconnect formation.

EXAMPLE 3: To test the workability of the underfill material in an attachment method that also involves an unfilled epoxy/phenolic material, an underfill composition was formulated according to the process of Example 1. The material was then placed on 25 mm x 25 mm glass cover slips and eutectic solder balls were placed on the coating which was then B-staged. An unfilled composition was also prepared. The unfilled epoxy/phenolic composition was formulated with 70 parts of RSL1739, 10 parts of Flex-1 and 10 parts of phenolic HRJ1166. These three resins were blended together without solvent and 0.5 parts of 2P4MZ/PMDA imidazole/anyhydride adduct and 10 parts of Corfree M2 were added. The resulting material was liquid at room temperature and had a viscosity of around 6,500 cP (6.5 Pa-s) at $1s^{-1}$. A drop of the unfilled composition was placed on a piece of FR-4 board with Cu finish. A 25 mm x 25 mm cover slip was coated with the filled epoxy/phenolic material, eutectic solder balls were placed in the coating and the assembly was B-staged. The cover slip containing the B-staged epoxy/phenolic coating was placed face down on the substrate, which had a drop of the unfilled composition on it. The above assembly was then put on a hot plate that had been preheated to 240 °C. Fluxing of the solder and the interconnection with the substrate was observed. The flow of the solder before the curing of the unfilled composition was also ensured by the latent curing provided by the 2P4MZ/PMDA adduct. The unfilled composition also flowed and formed a complete fillet around the cover slip before curing. The approach utilized in this example is compatible with the current surface mount technology. The surface tension of the unfilled composition helped to hold and self-align the cover slip during the reflow process. At the same time, the liquid form of unfilled composition provided better fillet formation, wetting and adhesion between the cover slip and the substrate. This

approach, utilizing two different materials for the chip and the substrate, also precluded the potential problem of air and filler trapping on the solder bump and wafer.

- 5 EXAMPLE 4: Five formulations of the underfill encapsulant composition were prepared according to the method of Example 1 as shown in Table 1. To determine the effect of the ratio and presence of the catalyst, the loading of the 2P4MZ/PMDA adduct was varied and in one formulation the catalyst was 2P4MZ instead of the adduct.

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Table 1. Epoxy/Phenolic Formulations with Different Catalysts

	EPON 826	HRJ 2190	2P4MZ/ PMDA	2P4MZ	Peak Curing Temp (°C)	Enthalpy Of Curing (J/g)
A1	50	50	0.5		172.9	33.2
A2	50	50		0.5	157.8	31.1
B1	50	50	0.4		181.0	53.6
B2	50	50	0.25		190.3	70.5
B3	50	50	0.1		203.4	90.4

- As shown in Table 1, the use of the 2P4MZ/PMDA adduct shifts the curing of the epoxy-phenolic system to temperatures at least 15 °C higher than those of the formulation using 2P4MZ. This temperature shift provides a longer time window for the eutectic solder to flux and form interconnections before the underfill has cured. When a solder-bumped chip coated with formulation A1 was passed through the reflow process, fluxing, reflow and interconnection of the solder bumps to the substrate were established. In the case of the bumped chips coated with formulation A2, the coating cured before the flow of the solder. Further, Table 1 illustrates that when the loading of the 2P4MZ/PMDA adduct is reduced, the curing is delayed to
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higher temperatures and the enthalpy of curing is also much higher. This suggests that any pre-curing during the B-stage can be minimized and the latent curing of the catalyst can be exploited more efficiently at lower catalyst loadings. The desired composition catalyst loadings, and thus different curing profiles, may be adjusted and chosen for different types of solder.

EXAMPLE 5: Two underfill encapsulants were formulated as shown in Table 2. The ratios of the epoxy and phenolic resins were varied to determine the effect of the ratio on the curing of the system.

Table 2. DSC Curing Results for Resin/Adduct

	EPON 826	HRJ 2190	2P4MZ/ PMDA	Peak Curing Temp (°C)	Enthalpy Of Curing (J/g)
C1	90	10	0.5	167.2	107.7
C2	80	20	0.5	166.7	219.9

Table 2 illustrates the effect of the blend of the epoxy/phenolic ratio on the enthalpy of curing. When the ratio of epoxy/phenolic is reduced from 9:1 to 4:1, the enthalpy of curing is more than doubled. This doubling may be attributed to more functional groups per weight of the phenolic resin. Three additional underfill encapsulants were formulated according to the method described in Example 1. As shown in Table 3, the proportions of the resins and adduct were changed. The coatings of these formulations were B-staged and their curing profiles were studied in DSC.

Table 3. DSC Curing Results for B-staged Coatings

	EPON 826	HRJ 2190	2P4MZ/ PMDA	Peak Curing Temp. (°C)	Enthalpy Of Curing (J/g)
D1	60	40	0.5	176.6	55.3
D2	57	43	0.5	175.5	50.6
D3	50	50	0.5	172.9	33.2

As shown in Table 3, with an increase in phenolic resin from 40 parts to 50 parts, the curing peak shifts to slightly lower temperatures. More importantly, the enthalpy of curing is decreased significantly. This result is the opposite of the result recorded for non-B-staged formulations and suggests that the higher phenolic content accelerates curing and results in substantial pre-curing during the B-stage. Thus, it is possible to tailor the epoxy/phenolic ratio and the catalyst content to achieve the desired amount of cure during the B-stage. The premature curing during the B-stage should be minimized since it greatly affects the flow properties during the attachment process. For example, the coating from formulation D3 had very poor substrate wettability and flow during the attachment process. Thus, the result was poor attachment between the chip and the substrate and little to no fillet formation around the package. The formulation D1 had lesser B-stage solidification and had good flow properties when attached to the substrate by heat and pressure. This formulation wetted the substrate completely and formed a complete fillet.

EXAMPLE 6. Two underfill encapsulant formulations were made according to the procedure set out in Example 1. To determine the effect of a fluxing

agent on the composition, rosin gum was added to one of the formulations, as set out in Table 4.

Table 4. DSC Curing Results with/without Fluxing Agent

	EPON 826	HRJ 2190	2P4MZ/ PMDA	Rosin Gum	Peak Curing Temp (°C)	Enthalpy Of Curing (J/g)
E1	50	50	0.5		172.9	33.2
E2	50	50	0.5	5	174.3	68.4

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As shown in Table 4, the addition of the rosin gum as a fluxing agent raises the curing peak to slightly higher temperatures. At the same time, the enthalpy of curing is also increased. The acid-based fluxing agent has the effect of retarding the solidification of the coating during the B-stage.

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EXAMPLE 7. An underfill encapsulant composition was formed via the method of Example 1. The encapsulant was coated on a 25 mm x 25 mm glass cover slip and eutectic solder balls were placed on the coating. The coating was B-stage solidified at 135 °C for 15 minutes. After the B-stage, the coatings were smooth, non-tacky and void free. The glass transition temperature of the coating was found to be around 46 °C by DSC. For the purposes of this Example, this first composition will be referred to as Material A.

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An unfilled liquid curable flux material was separately formulated with 90 parts of epoxy RSL1739 and 10 parts of phenolic HRJ1166. The two resins were blended together without solvent. 0.5 parts of the 2P4MZ and PMDA adduct and 10 parts of the fluxing agent Corfree M2 were added. The resulting material was a liquid at room temperature and had a viscosity of

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around 10,000 cP. For the purposes of this Example, this second composition will be referred to as Material B.

A drop of Material B was placed on a piece of FR-4 board acting as a substrate. The glass coverslip coated with B-staged solid Material A was placed face down on the substrate, so that Materials A and B were in contact with each other. The entire assembly was then placed on a hot plate that had been preheated to 240 °C. After the heating, it was observed that the areas of the solder balls increased, indicating solder fluxing and interconnect formation. Also, after the reflow process a complete fillet was observed around the cover slip.

EXAMPLE 8. This Example was conducted to determine the adhesion of packages assembled using the method of Example 7 versus those assembled without the unfilled liquid curable material. Initially, 2 mm x 2 mm silicon dies were coated with the epoxy/phenolic-containing underfill composition described in Example 1. The dies were B-staged at 125 °C under vacuum for 30 minutes to obtain a smooth, non-tacky coating on the surface of the dies. ½ inch x ½ inch pieces of FR-4 substrate board were cut and pre-baked at 150 °C for 40 minutes to eliminate any moisture. In the first test method (Method I), a drop of the unfilled liquid curable material was put on the pre-baked FR-4 substrate pieces and the dies were placed face down on the substrate. In the second test method (Method II), the silicon dies were placed directly on the bare FR-4 substrate pieces without the unfilled curable material on the substrate. The assemblies prepared according to both methods were then passed through the reflow oven to form packages. It was observed in the packages formed according to Method II that the filled underfill material spread out along the edges of the die, but did not climb

along the edges of the die to form a complete fillet. The dies prepared according to Method I formed a complete fillet around the chip boundary. The low-viscosity unfilled liquid curable material flowed nicely and climbed up along the edges of the chip to form the fillet. All chips were then tested via the Die Shear Test which records the highest force to shear the die from the FR-4 substrate. The peak shearing force was recorded by a Royce Instruments Die-Shear Tester. Twenty packages formed via each method were sheared and the average shear force was recorded. All the packages were found to fail at the chip/material A interface. The average peak force for the packages formed according to Method II was 13.5 ± 3.5 kgf. The average peak force for the packages formed according to Method I was 19.9 ± 2.6 kgf. The peak force before failure for the packages formed according to Method A was found to be higher due to larger fillets formed with the aid of the unfilled material B. Thus, the adhesion is increased by around 25% by coating the chip and the substrate with the two different but compatible materials before attachment. As understood in the art, good wetting and adhesion between those materials, and well formed fillet are essential for reliability of the packages. The die shear results are shown in Table 5.

Table 5. Die Shearing Test Results

	Force (kg/Peak Shear)
One Layer Package	10 – 17
Two-Layer Package (Filled B-Staged)	17 – 22.5
Two-Layer Package (Filled Layer Cured)	2.5 – 7.5